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(54) **Title**: A HIGH ASPECT RATIO ADHESIVE STRUCTURE AND A METHOD OF FORMING THE SAME

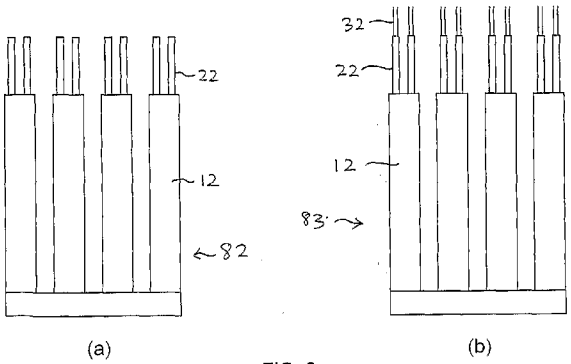


FIG. 2

(57) **Abstract**: A method of forming a high aspect ratio adhesive structure, the method comprising fabricating a porous template comprising at least a first tier and a second tier; introducing a softened polymer into the template; and separating the polymer from the template.